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- 1/1 DWPX (C) Thomson Derwent
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- Reduced carrier transient time semiconductor device forms spike barrier in valance band on hetero-junction surface between emitter and base NoAbstract Dwg 2/4
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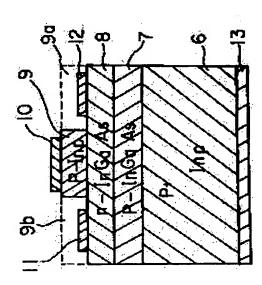
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(54) SEMICONDUCTOR DEVICE



(57)Abstract:

PURPOSE: To inject holes of high speed to a base, and to shorten the transient time of a small number of carriers by forming spiky barriers to a valence band in an emitter-base junction section and passing the barriers through holes, mobility thereof is originally low.

CONSTITUTION: A first layer p type InGaAs layer 7 is formed on an InP p+ substrate 6, and an n type InGaAs layer 8 is formed on the p type -InGaAs layer and a p type InP layer 9 further on the layer 8. AuGe/Au electrodes 11, 12 as base electrodes are formed on the second layer n-InGaAs layer 8 through etchings 9a, 9b up to the second layer n type InGaAs layer while leaving an emitter region in the third layer InP layer. Ohmic contacts are formed through allovings to form bases, Au/Zn/Au electrodes 10. 13 are shaped to the third layer p type InP layer 9 and the back of a p+ type InP 6, and emitter and collector electrodes are formed through the making of ohmics. Accordingly, a p-n-p hetero-junction bipolar transistor is formed.

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